## **Dispersing / Emulsifying / Mixing**

Advanced Nano Technology Co., Ltd. "Nano Maker"

# Cavitation Mill Nano Dispersing System



System Integration / Design / Sales / Engineering Support / Powder Processing Service

- Nano Creating (Grinding / Dispersion / Emulsifying / Classification) Systems
- Powder & Particles Processing Equipment / Systems



## FT Associates, Inc. (FTA)

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# FT Associates, Inc. (FTA)

Max Operation Pressure :200MPa

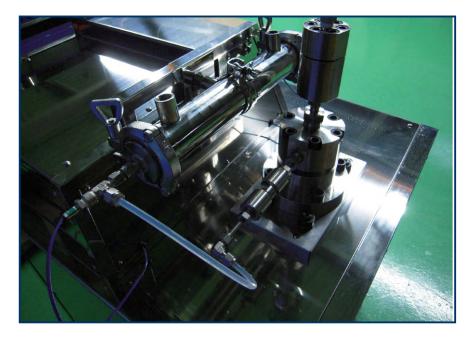
Max Flow Rate: 10L/Hr

Max Operational Pressure: 200MPa

Max Flow Rate: 15L/Hr









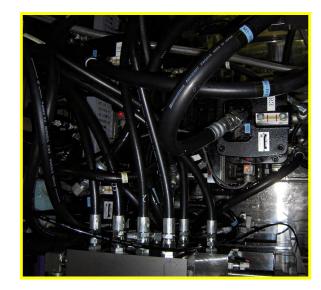








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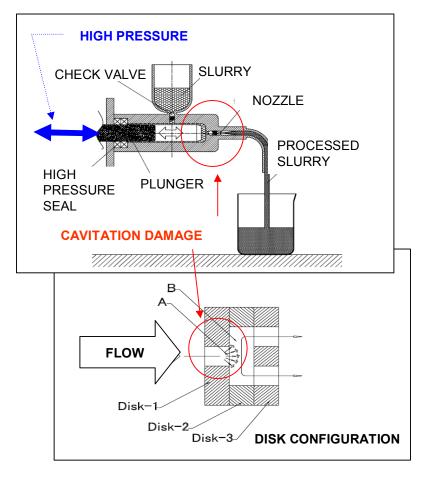








### **■** PRINCIPLE



CAVITIES ARE EFFECTIVELY GENERATED THROUGH THE SEPCIAL DESIGNED DISKS AND NOZZLE CONFIGURATION, AND THEN RAPIDLY COLLAPSED, RELEASING VERY HIGH ENERGY OVER THE PARTICLES.

THE PROCESS, "CAVITATION DAMAGE", ENFORCES THE <u>DISPERSING</u>, & <u>EMULSIFYING</u> TO CREATE SUCH FINE NANO PARTICLES.

"ULTRA HIGH PRESSURIZED FLOW", "BEST FORMATION OF DIAMOND DISK ", & "EFFICIENT NOZZLE ARRANGEMENT" ENSURE THE PERFECT DEVELOPMENT AND COLLAPSE OF CAVITIES, DISCHARGING SUCH HIGH ENERGIES (CAVITATION DAMAGE), AND IMPROVE THE BASIC FUNCTIONS, CRUSHING, DISPERSING, EMULSIFYIUNG, BY SUCH A HIGH EFFICIENT CAVITION DAMAGE PROVIDE LONGER PARTS LIFE



**High Pressure Pump** 



## **■ FEATURES**

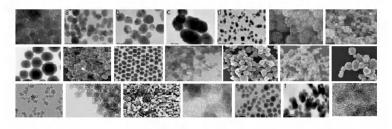
NOT TO DAMAGE CRISTAL & SURFACE FORMS

TO IMPROVE THE SHARP PARTICLE DISTRIBUTION

TO ENSURE CONTINUOUS OPERATION UNDER VERY SIMPLE PROCEDURE

TO PRODUCE PURE MATERIALS WITHOUT CONTAMINATION

TO CREATE VARIOUS RANGE OF PARTICLES WITH ADJUSTABLE PRESSURE RANGE



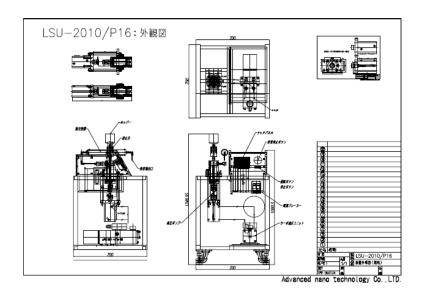


#### APPLICATIONS

# NANO DISPERSING OF THE ADVANCED FUTURE MATERIALS FOR

- FPD (FLAT PANEL DISPLAY) COATING,
- SYSTEM ON FILM,
- ELECTRONICS DEVICES,
- HYBRID INJECTION MOLDING &
- OTHER APPLICATIONS

CARBON BLACK, RARE METALS, NICKEL, ALUMINA, ZIRCONIUM, CARBON NANO TUBE, COSMETIC MATERIALS, CERAMICS, FERRITE MIX POWDER, ALUMINUM CHLORIDE, CARBON MATERIAL, DRUG MATERIAL, METAL POWDER, GRAPHITE, SILICA, FOOD ADDITIVES, INDIUM, COBALT, ZINC OXIDE, TITANIUM OXIDE, MAGNETIC FLUID (MSG-W11), CALCIUM MILK BAKING, ZIRCONIUM, CALCIUM CARBONATE, SOY LECITHIN, NICKEL, COPPER PHTHALOCYANINE



#### OTHER MAJOR EXAMPLE:

SILICA FOR CPM SLURRY (SEMICONDUCTOR POLISHING)
SILICONE OIL FOR COSMETICS, LUBRICANTS
ORGANIC AND INORGANIC PIGMENTS FOR FPD INK FOR COLOR FILTERS AND SOLAR
CELLS, CARBON, LITHIUM, NICKEL FOR ELECTRODE MATERIAL FOR RECHARGEABLE BATTERIES ZINC
OXIDE, TITANIUM OXIDE FOR PHOTOCATALYTIC, OPTICAL RECORDING MATERIALS BARIUM TITANATE
FOR DONDENSER OTHER ELECTRONIC MATERIALS
PHARMACEUTICAL MATERIALS FOR DRUGS
SOY LECITHIN POWDER SOY: EMULSIFICATION / FOOD, LIQUID FOOD, HEALTH FOOD
YEAST FOR FRAGMENTATION (THE EXTRACTION OF CONTENTS)

# ■ High Pressurized Nano Dispersing / Emulsifying Lab System Model LSU-2010/P16 • LSU-2010/P14

Ultra high pressurized (up to 200MPa) slurry flow design, with the best formation of diamond disks, & efficient nozzle arrangement based on long established experience, and know-hows over 400 production and lab systems delivery in the past 20 years.

- ensure the perfect development and collapse of cavities, discharging such high energies (Cavitation Damage)
- improve the basic functions, dispersing, emulsifying, by such a high efficient cavitations damage
- Easy set-up, cleaning, and maintenance is realized
- Best interface between man-machine is achieved.
  - \* Pressure Control System keeps **stable continuous pressure**
  - \* Operation parameters (pressure level, slurry flow condition, temperature, and others) can be observed simultaneously on touch panel
  - \* Operation parameters can be input on easily from the touch panel
  - \* Process failure diagnosis system can tell, and show the operator the inadequate operation factors.



LSU-2010/P16



DSU-2515/P16







# **■** TEST RESULTS

	BEFORE PF	ROCESSING		AFTER PROCESSING		REMKARKS	
MATERIALS	D50( μ m)	D90( μ m)	SOLVENT	D50( μ m)	D90 (μm)	ILIVIINALINO	
ALUIMINA	3.41	5.10	WATER	1.98	3.40	150MPa / 1pass	
INDIUM	0.34	2.12	ETHANOL	0.08	0.12	130Mpa / 3pass	
CARBON BLACK	25.13		WATER	0.98		130Mpa / 2pass	
COBALT	6.72	11.80		1.73	2.98	150MPa / 3pass	
ZINC OXIDE	3.60	6.70	WATER	0.45	1.32	100MPa / 3pass	
TITANIUM OXIDE	19.20			0.23		100MPa / 3pass	
MAGNETIC MATERIAL (MSG-W11)	0.38			0.08		100MPa / 5pass	
ZIRCONIUM	26.80		WATER	0.46		100MPa / 3pass	
CALCIUM CARBONATE	0.45	1.51	WATER	0.18	0.24	150MPa / 3pass	
NICKEL	0.88	4.47		0.41	0.52	150MPa / 3pass	
γ-HEMUTITE	2.00			0.43		100MPa / 3pass	
LITIUM ALUMINATE(LiAlO2)	19.78			0.32		100MPa / 3pass	

# ■ NANO MAKER MAJOR SYSTEM SPECIFICATIONS

model	LSU-2010P16	DSU-2515P16	PU-2 **** P ***	
Explosion-proof / Non- explosion-proof	Non-explosion-proof	Non-explosion-proof	Explosion-proof / intrinsically safe instrumentation can be designed	
Drive system	Servo-hydraulic unit	Servo-hydraulic unit	Hydraulic unit	
Pump type	constant plunger pump	constant plunger pump	constant plunger pump	
Performance	Double acting / single rod	Double acting / single rod	Double acting / single rod	
Plunger No.	1	1	1 to 3	
Plunger diameter (mm)	16	16	14-100	
Stroke (mm)	100	100	100	
Plunger material	Zirconia / HIP process	Zirconia / HIP process	Zirconia / HIP process	
Maximum number of sliding (regular use)	16	16	15-20	
Maximum pressure (MPa) (regular use)	200	250	Max.250	
Maximum capacity (L / hr) (regular use)	Ten	Fifteen	15-500	
High-pressure seal shape	Forming U-seal / made to order	Forming U-seal / made to order	Forming U-seal / made to order	
High-pressure seal material	Solvent-resistant resin	Solvent-resistant resin	Solvent-resistant resin	
Materials of slurry contact part	SUS316 / zirconia ceramic / metal carbide / resin solvent- resistant polyethylene polymer / sintering diamond / diamond single crystal	SUS316 / zirconia ceramic / metal carbide / resin solvent- resistant polyethylene polymer / sintering diamond / diamond single crystal	SUS316 / zirconia ceramic / metal carbide / resin solvent- resistant polyethylene polymer / sintering diamond / diamond single crystal	
Dimensions (mm)	600 (W) × 700 (D) × 1300 (H)	700 (W) × 700 (D) × 1300 (H)	Specifications may vary	
Control / power cubic box	AC 200V / 3 phase power 1.7KW	AC 200V / 3 phase power 2.5KW	AC 200V / 3 phase power, control / power board in place by self-explosion-proof areas	
Estimated body weight (Kg)	120	140	450	

# FT Associates, Inc. (FTA)

**Inquiry Sheet** Please fill your requirement / Information & return to us.

Customer	Company					Dept. Position				
	Address					Phone				
	Name					E-Mail				
Required System &	Category	A) Grinding B) Dispersing / Emulsifying C) Classification / Sifting D) Feeding / Transportation E) Separation / Concentration F) Drying G) Others								
Request										
	System	A) Cavitation Mill Dispersing System B) Beads Mill Ultra Fine Grinding System C) Jet Mill Ultra Fine Grinding System D) Grinding Mill Powder Pulverization System E) Super Micro Sieve F) Hydro-Cyclone Classification System G) Vibration Sifter H) Micro Powder Air Classifier I) Constant Micro Feeder J) Others								
	Request	A) Sales Material B) Proposal C) Test D) Process Service E) Rental F) Others								
Materials	Name					Properties	Bulk Density		Moisture	
Target	Condition	A) Powder B)	A) Powder B) Particle C) Solid D) Others			Y or N	Hygroscopic		% if Yes	
							Abrasiveness		Aggregation	
	Particle	A) Spherical B) Unspecified C) With Protrusion D) Single Particle E) Aggregates F) Unknown				Viscosity		Adhesion		
	Shape	Particle E) A	ggregates F) Offic	HOWII		Solvent	A) Water B) Etha E) Acetone F) To H) Ethyl Acetate	anol C) IPA D) MEK foluene G) Xylene I) Others		
	Size	Ori	ginal Powder		Required					
	D <sub>50</sub>					Slurry	Density wt%		Viscosity cps	
	Тор							•		
	Others	<u>'</u>				Detergent				
Test Required		Volume Test sample		Production						
Work	Т	Test / Work Schedule					Attendance			
Remarks										

Excel version is available at <a href="http://www.ftajapan.com/inquiry.xls">http://www.ftajapan.com/inquiry.xls</a>, if required.

1/7/2013 X01

# Major Systems & Services offered by FTA



## Grinding / Crushing / Dispersing / Emulsifying

Dispersing / Emulsifying / Mixing Wet Operation Cavitation Mill Nano Dispersing System

Nano Grinding / Crushing / Dispersing / Mixing Wet Operation
Beads Mill Nano Grinding System

**Grinding / Crushing Dry Operation Jet Mill Ultra Fine Grinding System** 

Dispersing / Emulsifying / Mixing Wet Operation

**Ultrasonic Processor Nano Forming System** 

Grinding, Crushing Dry Operation
Grinding Mill Powder Pulverization System



### Classifying / Sifting

Classification / Sifting Dry & Wet Operation Super Micro Sieve & Screen

Classification/Separation/Concentration Wet Operation Hydrocyclone Classification System

Sifting / Screening / Classifying Dry & Wet Operation Powder & Particles Vibration Sifter

**Classifying Dry Operation**Micro Powder Air Classifier



## Other Powder Processing Systems & Services

Concentration

**Screw Decanter Concentration System** 

**Constant Feeding** 

Powder & Partciles Constant Micro Feeder

1/7/2013 X02